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Title: **JP53052354A2: SEMICONDUCTOR LOCAL HEATING METHOD**

Country: JP Japan  
Kind: A

Inventor(s): SHIMIZU NOBUO

Applicant/Assignee:



**HITACHI LTD**

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Issued/Filed Dates: **May 12, 1978 / Oct. 25, 1976**

Application Number: **JP1976000127226**

IPC Class: **H01L 21/22; H01L 21/20; H01L 21/268;**

Priority Number(s): Oct. 25, 1976 **JP1976000127226**

Abstract: **Purpose:** The modes of heat treatment are made various and such a treatment method which had been impractical with conventional heat treatments is made possible by using a laser beam in locally heating a semiconductor wafer.

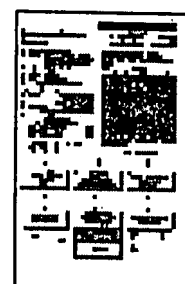
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Family: Show known family members

Other Abstract Info: none

Foreign References: No patents reference this one



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